Electronic Acknowledgement Receipt		
EFS ID:	1214265	
Application Number:	10642518	
Confirmation Number:	1585	
Title of Invention:	Balanced Al-Cu-Mg-Si alloy product	
First Named Inventor:	Rinze Benedictus	
Customer Number:	24257	
Filer:	Anthony Peter Venturino	
Filer Authorized By:		
Attorney Docket Number:	APV31645	
Receipt Date:	22-SEP-2006	
Filing Date:	18-AUG-2003	
Time Stamp:	11:23:34	
Application Type:	Utility	
International Application Number:		
Payment information:		
Submitted with Payment	yes	
Payment was successfully received in RAM	\$1020	
DAM andisenting Number	1	

	File Listing:	•	40	
I	Deposit Account			
	RAM confirmation Number	847		

Document Number	Document Description	File Name	File Size(Bytes)

Warnings: Information:					
Warnings:					
3	Fee Worksheet (PTO-875)	fee-info.pdf	8122	no	2
Information:					
Warnings:					
2	Amendment - After Non-Final Rejection	APV31645_Amendment_efs _submission.pdf	146616	no	13
Information:					
Warnings:					
1	Extension of Time	APV31645_xot_efs_submiss ion.pdf	81872	no	2

This Acknowledgement Receipt evidences receipt on the noted date by the USPTO of the indicated documents, characterized by the applicant, and including page counts, where applicable. It serves as evidence of receipt similar to a Post Card, as described in MPEP 503.

New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.